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APPLICATION NO.	FILI	NG DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	ATTORNEY DOCKET NO. CONFIRMATION NO.	
10/616,132	07/	08/2003	Jiann-Shuoh Liaw	JCLA7920	2096	
23900	7590 .	04/19/2005		EXAMI	EXAMINER	
J C PATEN' 4 VENTURE		0	ULLAH, AKM E			
IRVINE, CA		U		ART UNIT	PAPER NUMBER	
				2874		
				DATE MAILED: 04/19/2005	;	

Please find below and/or attached an Office communication concerning this application or proceeding.

			<u></u>			
	Application No.	Applicant(s)				
	10/616,132	LIAW, JIANN-SHUOH				
Office Action Summary	Examiner	Art Unit				
	Akm Enayet Ullah	2874				
The MAILING DATE of this communication Period for Reply	appears on the cover sheet wit	h the correspondence address				
A SHORTENED STATUTORY PERIOD FOR RE THE MAILING DATE OF THIS COMMUNICATIO - Extensions of time may be available under the provisions of 37 CFF after SIX (6) MONTHS from the mailing date of this communication - If the period for reply specified above, the maximum statutory pe - Failure to reply within the set or extended period for reply will, by standard patent term adjustment. See 37 CFR 1.704(b).	N). R 1.136(a). In no event, however, may a re . I reply within the statutory minimum of thirty riod will apply and will expire SIX (6) MONT atute, cause the application to become AB/	oply be timely filed (30) days will be considered timely. THS from the mailing date of this communication ANDONED (35 U.S.C. § 133).	cation.			
Status						
1) Responsive to communication(s) filed on _						
	This action is non-final.					
3) Since this application is in condition for allo	wance except for formal matte	ers, prosecution as to the meri	its is			
closed in accordance with the practice under	er <i>Ex part</i> e Quayle, 1935 C.D.	. 11, 453 O.G. 213.				
Disposition of Claims	-	·				
4) ⊠ Claim(s) 1-22 is/are pending in the applicat 4a) Of the above claim(s) is/are withe 5) □ Claim(s) is/are allowed. 6) ⊠ Claim(s) 1-22 is/are rejected. 7) □ Claim(s) is/are objected to. 8) □ Claim(s) are subject to restriction and	drawn from consideration.					
Application Papers						
9) The specification is objected to by the Exam	niner.					
10)☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.						
Applicant may not request that any objection to	the drawing(s) be held in abeyan	ce. See 37 CFR 1.85(a).				
Replacement drawing sheet(s) including the cor	,	•	• •			
11) The oath or declaration is objected to by the	Examiner. Note the attached	Office Action or form PTO-15	i2.			
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for fore a) All b) Some * c) None of: 1. Certified copies of the priority docum 2. Certified copies of the priority docum 3. Copies of the certified copies of the papplication from the International But * See the attached detailed Office action for a	nents have been received. nents have been received in Appriority documents have been reau (PCT Rule 17.2(a)).	pplication No received in this National Stage	e			
Attachment(s)						
1) Notice of References Cited (PTO-892)	4) Interview S	ummary (PTO-413)	7			
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s	:)/Mail Date				
Information Disclosure Statement(s) (PTO-1449 or PTO/SB Paper No(s)/Mail Date	6) Other:	formal Patent Application (PTO-152) —·				

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Detailed Action

Applicant cooperation is requested in correcting any errors of which applicant may become aware in the specification.

Status of the Application

Claims 1- 22 are pending in this application.

Claims 12-20 are allowable over the prior art as of record.

If applicant is aware of any prior art or any other co-pending application not already of record, he/she is reminded of his/her duty under 37 CFR 1.56 to disclose the same.

If applicant provides prior art, he/she is requested to cite it on form PTO-1449 in accordance with the guideline set forth in MPEP 609.

Drawings

This application has been filed on July 08, 2003 with informal drawings, which are acceptable for examination purposes only.

Formal drawings will be required when the application is allowed.

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Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in

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order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

Claims 1-22 are rejected under 35 U.S.C. 103(a) as being unpatentable over Fuchs et al (USPNO. 6,795,198) or Banet et al (USPNO. 6,118,533).

Both references disclose a method and apparatus comprising

the steps of:

providing a substrate (figure 1, numeral 10 of Banet et al and figure 1A, numeral 11 of Fuchs et al) with a polished surface having a plurality of reflective regions thereon,

providing a pulsed laser beam (figure 1A, numeral 12' & 12" of Fuchs et al and figure 1, numeral 12' & 12" of Banet et al) that shines on the reflective regions on the substrate to produce a grating pattern through optical interference

providing a cylindrical lens (optical system consist of lens in Fuchs et al and beam delivery system consists of lens in Banet et al) for adjusting the configuration of the grating pattern.

Regarding reflective region has at least a reflective surface such that all the reflective surfaces are parallel to each other as claimed in claims 4 & 15 and,

the light incident surface comprises a plane rectangular surface as claimed in claims 9 & 22 are clearly shown in figures 1 and 1A of the both references.

Regarding claims 7-9, and 17-19 the limitations of a protective layer is fabricated using a dielectric material and the lens is being a cylindrical lens is mentioned in column 8, last paragraph of Fuchs et al.

Regarding claims 10 & 21 wherein the grating pattern produces a surface acoustic wave transmission on a surface film of the substrate is very elementary teachings in this art

and also being discussed by both references (page 2 of Fuchs et al and column 11, first paragraph of Banet et al).

Both references differ from the claimed invention because he does not explicitly disclose the Vicker's microhardness tester as claimed in claims 2 & 13.

Banet et al is the evidence that ordinary skill in the art would find a reason, suggestion or motivation to have the Vicker's micro-hardness tester in any one of the above mentioned reference since, column 1 of Banet et al explained a conventional semiconductor fabrication process in a typical optical method and apparatus.

Therefore, it would have been obvious to one of ordinary skill in the art at the time of the invention was made to modify the method and apparatus of any one of the above mentioned reference using Vicker's micro-hardness tester in order to perform a imprinting operation as claimed.

It is noted that applicant has not described such Vicker's micro-hardness tester as being critical or as yielding unexpected benefits. Certainly a person of ordinary skill in the art would find it beneficial to achieve more uniform bright and dark line distribution, a better bright and dark line contrast and higher resolution wherever possible.

Claims Are Allowed

Claims 12-20 are allowed over the prior art as of record.

Contact Information

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Akm Enayet Ullah whose telephone number is 571-272-2361. The examiner can normally be reached on Monday through Wednesday from 5:30 am to 4 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Rodney Bovernick, can be reached on Monday through Friday @ 571-272-

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2344. Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

> Ákm Enayet Ullah Primary Examiner Art Unit 2874

Aullah

April 07,2005